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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)) ATTORNEY FILE NO.:
Inventors: Joshi et al.)	SLA0786
Serial No.: 10/812,591))
Filed: March 29, 2004)) Examiner: Sarkar, Asok
Title: HIGH DENSITY PLASMA PROCESS FOR THE TRANS- FORMATION OF SILICON DIOXIDE ON SILICON CARBIDE SUBSTRATES)) Customer No.: 55,286
)) Group Art: 2891
)) Confirmation No.: 2314
))

Mail Stop Amendments
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

CERTIFICATION UNDER 37 CFR § 1.8

I hereby certify that this correspondence is being facsimile transmitted to the US Patent and Trademark Office, fax No. 571 278 8300, on this date 4/6/2006.

Date

4/6/2006

Signature



RESPONSE UNDER 37 CFR 1.111

In response to an Office Action mailed January 18, 2006,
please amend and reconsider the above-referenced application as follows.

Amendments to the specification begin on page 2 of this
paper.

Amendments to the claims begin at page 3 of this paper.

Remarks begin at page 16 of this paper.

Attached is the affidavit of Dr. Yoshi Ono.

Attached are a fee determination record and a PTO-2038
credit card payment form.

04/07/2006 TL0111 00000005 10812591

01 FC:1201
02 FC:1202

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